AMENDMENTS TO THE CLAIMS

- 1. (Original) A composition for formation of an antireflection film prepared by dissolving, in an organic solvent, (A) a ladder-type silicone copolymer consisting of (a,) 10-90% by moles of (hydroxyphenylalkyl)silsesquioxane units, (a2) 0-50% by moles of (alkoxyphenylalkyl)silsesquioxane units and (a3) 10-90% by moles of alkyl- or phenylsilsesquioxane units, (B) an acidgenerating agent capable of generating an acid by heat or light and (C) a crosslinking agent and having a characteristic to be capable of forming an antireflection film of which the optical parameter (k value) relative to ArF lasers is in the range of 0.002-0.95.
- **2. (Original)** The composition for formation of an antireflection film described in Claim 1 which further contains (D) a linear polymer in addition to the component (A), component (B) and component (C).
- **3.** (Original) The composition for formation of an antireflection film described in Claim 2 in which the said (D) linear polymer is a polymer containing hydroxyl group-containing (meth)acrylic acid ester units.
- **4. (Original)** The composition for formation of an antireflection film described in Claim 3 in which the said (D) linear polymer is a polymer containing (meth)acrylic acid ester units having hydroxyl group-containing aliphatic polycyclic groups.
- **5.** (Original) The composition for formation of an antireflection film described in Claim 3 in which the said (D) linear polymer is a linear copolymer consisting of 10-60% by moles of the constituent units (d_i) represented by the general formula,

(In the formula, R' is a hydrogen atom or a methyl group and R^2 is an alkyl group), 30-80% by moles of the constituent units (d_2) represented by the general formula,

(R^3 in the formula is a hydrogen atom or a methyl group) and 10-50% by moles of the constituent units (d_3) represented by the general formula,

(R⁴ in the formula is a hydrogen atom or a methyl group).

6 to 9. (Canceled)